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Se-doped MoS₂ nanosheet for improved hydrogen evolution reaction

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Thanks to the increase in number of active sites and enhanced conductivity, the Se-doped MoS₂ has excellent catalytic activity with a lower overpotential of 140 mV and a smaller Tafel slope of 55 mV/dec, exhibiting enhanced catalytic performance compared with that of pristine MoS₂. This work offers an attractive strategy to improve HER activity of MoS₂-based catalysts.

With very high energy density, hydrogen is considered as an ideal clean energy carrier that generates only water after its combustion.¹ The environmentally friendly electrocatalytic water-splitting is an important process for the hydrogen production. Conventionally, Pt-group metals are the most efficient electrocatalysts for the hydrogen evolution reaction (HER), but their limited resource and extremely high cost hinder their commercial application of this technology.^{2,3} Thus, it is desirable, no matter how challenging it is, to find inexpensive alternatives with high electrocatalytic activity to replace the Pt in the HER catalysts. Recently, nanostructured molybdenum sulfides (MoS₂) have been identified as potential substitutes for the Pt-group catalysts because the free energy of atomic hydrogen bonding to the sulfur edge of the MoS₂ structure is very close to that of Pt.⁴⁻⁶ However, the catalytic HER performance of MoS₂ is currently limited by availability of number of the active sites and poor conductivity.⁷⁻⁹

There have been enormous attempts focusing on the improvement of either the number of active sites or the conductivity of MoS₂ electrocatalysts to enhance their HER activity. For the former one, increasing the active edge area of the MoS₂ by introducing nanoscale is an efficient strategy, for example, ultrathin MoS₂ nanoplates,¹⁰ defect-rich MoS₂ nanosheets,¹¹ and MoS₂ quantum dots,¹² are used to obtain

good catalytic performance. For the second one, the catalysts were loaded on highly conductive matrices, such as carbon nanotubes,¹³ conductive polymer and graphene,¹⁴⁻¹⁸ to form MoS₂-based hybrids or composites, and exhibit much higher catalytic activity than their pure MoS₂ counterpart. Meanwhile, the metallic 1T-MoS₂ shows better HER performance than the semiconducting 2H-MoS₂ phase.¹⁹ However, the 1T-MoS₂ is thermodynamically metastable and turns into 2H-MoS₂ upon heating at moderate temperatures or aging in air.²⁰

It is also found that the HER activity of MoS₂ electrocatalysts can be tuned through tailoring their chemical composition. For example, cobalt or nickel doping, and vanadium doping all can promote the electrocatalytic performance of MoS₂.^{21, 22} Inspired by the inventions, we believe that the anion-doping to MoS₂ may also be used to improve the HER activity, such as selenium (Se) doping. At least the Se atom doped into the frameworks of MoS₂ will improve the electrical conductivity because of more metallic nature of Se. This factor motivated our curiosity in exploring the use of Se-doped MoS₂ materials as catalysts for HER.

Herein we described our success in preparation of Se-doped MoS₂ nanosheets via a facile annealing process using diphenyl diselenide (DDS) as the Se dopant. The overall formation process is depicted in Fig. 1a. More details on the synthesis procedure is given in the experimental section (see the ESI†). Benefiting from the high active edge sites and enhanced electronic conductivity by Se doping, the Se-doped MoS₂ exhibits an excellent electrocatalytic activity for the HER with substantial current densities and a small Tafel slope of 55 mV/dec.

Fig. 1b shows the XRD patterns of pristine MoS₂ and Se-doped MoS₂ nanosheets. All peaks can be assigned to hexagonal 2H-molybdenum dichalcogenide with no discernible impurities, revealing the high purity of the product. After Se doping, all main diffraction peaks slightly shifted toward smaller diffraction angles (see Fig. 1c, Fig. S1a-c), indicating that there is an increase in the interplanar distance as the Se atom is larger than S. Besides, it is also clear that the XRD

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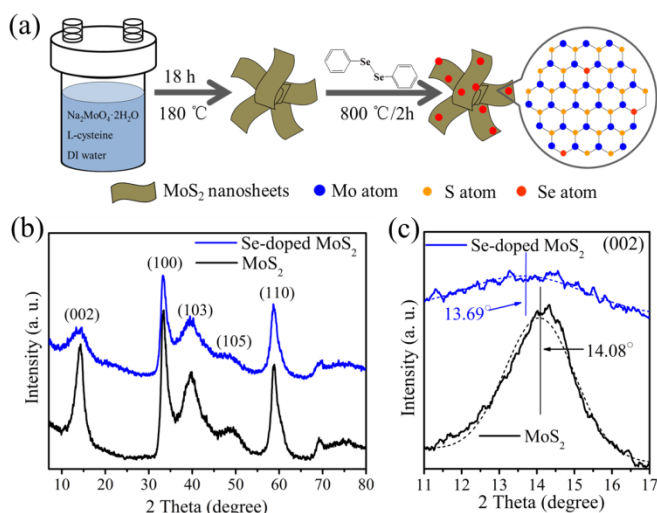


Fig. 1 (a) Schematic illustration of synthesis procedure for the Se-doped MoS₂ nanosheets. (b) XRD and (c) the enlarged (002) crystal plane of MoS₂ and Se-doped MoS₂ nanosheets; For (c), the solid lines are experimental data and the dotted lines are the corresponding Gaussian fittings.

peaks of the Se-doped MoS₂ are broader and weaker in intensity (Fig. 1b and c), indicating that reducing the average grain size and the crystallinity, and increasing defective and disorderly structures in the Se-doped MoS₂ due to their open edges after Se doping.

The morphology and detailed microstructure of the Se-doped MoS₂ was studied by transmission electron microscopy (TEM) and high-resolution TEM (HRTEM) images and compared to those of pristine MoS₂ (Fig. 2 and Fig. S2). It shows that the basic morphology of nanosheets was retained after the Se doping. Fig. 2b reveals the lamellar structure and a large number of exposed edge sites of the (002) plane of Se-doped MoS₂. Comparing the HRTEM images of pristine and Se-doped MoS₂ (Fig. 2c and Fig. S2b), it appears that: (1) Se-doped MoS₂ shows a more disorderly and defective lattice fringes, indicating the disordering of atomic arrangements and the reduced crystallinity, as confirmed by the corresponding electron diffraction pattern (inset of Fig. 2c); (2) Se-doped MoS₂ shows slightly different spacing between adjacent (002) planes. As shown in Fig. 2d, the red line covers 2.145 nm in length and scan spans 3 different spacing of 0.882 nm, 0.601 nm and 0.662 nm, respectively; the green line covers 2.219 nm in length and scan spans 3 different spacing of 0.641 nm, 0.855 nm and 0.723 nm, respectively. It is apparent that the Se doping has caused lattice spacing expanded from 0.60 nm to over 0.88 nm, as witnessed by the XRD results. It should be noted that this disordered and defective lattice structure is desired for us for it generates increased number of active edge sites and improved overall catalytic activity for HER.

Fig. S3 shows Raman spectra of Se-doped MoS₂ using 532 nm laser excitation. Two characteristic peaks, in-plane (E_{2g}^1) and vertical plane (A_{1g}), are clearly resolved at $\sim 378\text{ cm}^{-1}$ and 403 cm^{-1} .²³ By introducing Se, both peaks are shifted to lower

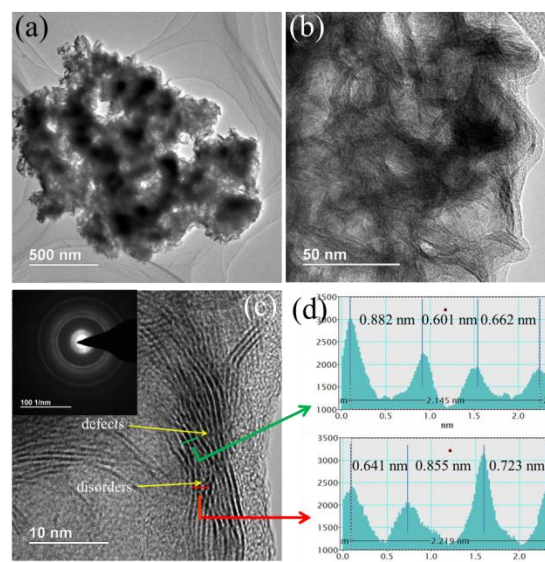


Fig. 2 (a and b) TEM images of Se-doped MoS₂ nanosheets. (c) High-magnification TEM image and (inset) the corresponding SAED patterns of Se-doped MoS₂ nanosheets. (d) The lattice distances of the labeled green and red lines in (c), HRTEM shows the spacing between adjacent (002) planes.

frequency and intensity reduced. The frequency shift is caused by the interaction between S and Se atoms, leading to softer Mo-S vibration and decreased frequency;^{24, 25} Meanwhile, the reduced Raman intensity is likely a consequence of the change in lattice symmetry that determines the matrix elements and selection rules for Raman active vibrational modes.²⁶ In addition, Se-doped MoS₂ gives a larger E_{2g}^1/A_{1g} value than that of pristine MoS₂ (0.56 vs. 0.46), resulting in abundant edge structures.^{27, 28}

X-ray photoelectron spectroscopy (XPS) was used to examine the chemical states and the Se content in the as-synthesized Se-doped MoS₂ nanosheets. Fig. 3a-c illustrates the Mo 3d, S 2p, and Se 3d high resolution spectra of Se-doped MoS₂. As shown in Fig. 3a, two characteristic peaks located at 229.3 eV and 232.5 eV are attributed to Mo⁴⁺ 3d_{5/2} and 3d_{3/2}, suggesting the dominance of Mo⁴⁺ in the sample.²⁹ The peaks at 162.2 and 163.4 eV in Fig. 3b are attributed to S²⁻ 2p_{3/2} and S²⁻ 2p_{1/2}, respectively.³⁰ The peak at 161.0 eV is attributed to Se 3p_{3/2}. The Se 3d peak is split into well-defined 3d_{5/2} and 3d_{3/2} peaks at 54.5 and 55.4 eV (Fig. 3d),³¹ a well known characteristic of substitutional doping of Se to S, in comparison of S occupying the interstitial sites of MoS₂. Quantification analysis of the Se 3d and S 2p peaks gives the Se doping concentration in MoS₂ $\sim 5.7\%$. Moreover, typical scanning transmission electron microscopy (STEM) and elemental mapping images of Se-doped MoS₂ nanosheets are presented in Fig. 3d-g, it is clear that all elements (Mo, S, Se) are distributed uniformly in the sample. It is worth noting that even high resolution ADF analysis did conclude not-so-uniform Se distribution in an earlier report by Y. Gong,³² for probing size $\sim 500\text{ nm}$ using low resolution TEM mapping for present

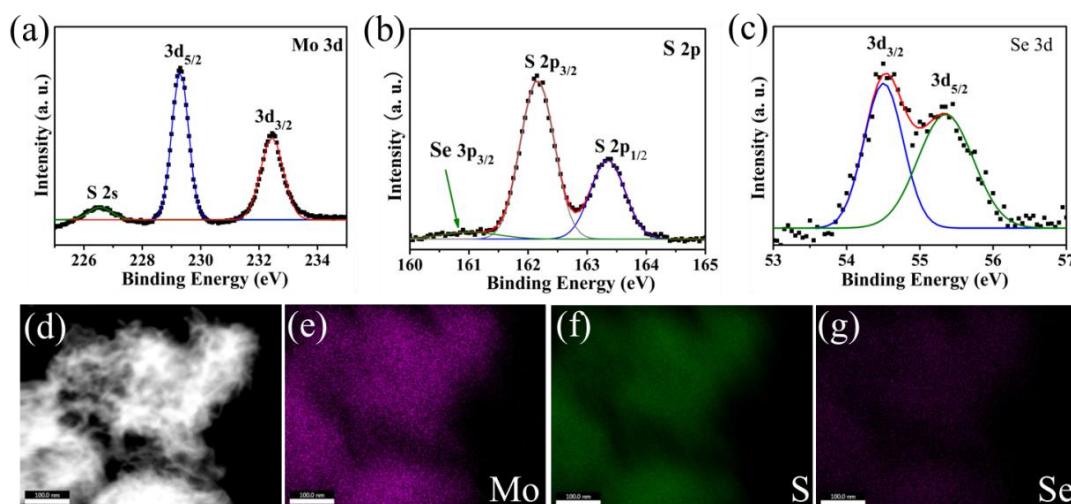


Fig. 3 High-resolution XPS spectra of Mo 3d (a), S 2p and Se 3p (b), Se 3d (c) of the Se-doped MoS₂ nanosheets. (d) STEM-bright field image of the Se-doped MoS₂ nanosheets. (e-g) Elemental mapping of Mo, S and Se from the region shown in (d), respectively (scale bars, 100 nm).

samples, all three elements (Mo, S, Se) show fairly consistent distribution.

The HER using MoS₂ and Se-doped MoS₂ nanosheet catalysts were measured using the standard three-electrode electrochemical configuration in 0.5 M H₂SO₄. The catalysts were loaded on glassy carbon carrier and the electrolyte de-aerated with N₂, and more details are described in the Experimental section. For comparison, commercial Pt electrode was used as the reference. As shown in Fig. 4 a, the Pt catalyst exhibits extremely high HER catalytic activity with a very low onset overpotential ($\eta \approx -40$ mV). Pristine MoS₂ displays weak HER performance with a high onset potential and a weak cathodic current density. In contrast, the Se-doped MoS₂ shows much higher HER activity with a small onset overpotential ~ -140 mV, beyond this potential the cathodic current increased rapidly. It is clear that at $\eta = -400$ mV, the Se-doped MoS₂ exhibits an extremely large cathodic current density 42.7 mA/cm², ~ 4 times larger than what observed in MoS₂ (11.2 mA/cm²).

To further study the catalytic activity of Se-doped MoS₂ nanosheets, Tafel plots derived from the polarization curves were used to determine the Tafel slopes. As shown in Fig. 4 b, the Tafel slope of the Pt catalyst is ~ 35 mV/dec, very similar to what reported in literature.³³ The Tafel slope of Se-doped MoS₂ is 55 mV/dec, even though it is indeed larger comparing to Pt, it is much smaller than that of the pristine MoS₂ (89 mV/dec). Considering that not only the onset overpotential is reduced, its Tafel slope is much improved, the Se-doped MoS₂ is clearly demonstrated with much enhanced catalytic activity.

Notably, the HER performance of the obtained Se-doped MoS₂, within the context of onset potential (-140 mV), and Tafel slope (55 mV/dec), is markedly better than those of undoped MoS₂ catalysts, such as MoS₂ nanosheets (-180 mV, 87 mV/dec), nanosized bulk MoS₂ (-280 mV, 82 mV/dec), MoS₂ nanoparticles (-160 mV, 77 mV/dec), and comparable

to other doped MoS₂ catalysts, such as V-doped MoS₂ (-130 mV, 60 mV/dec) and oxygen-incorporated MoS₂ (-120 mV, 55 mV/dec). However, there are indeed reports using composites to achieve even better activity (Table S1).

The enhanced catalytic activity of Se-doped MoS₂ may be attributed to two factors: (1) Incorporation of Se into MoS₂ reduces the average grain size, therefore resulting in more active edge sites, as confirmed by the TEM, XRD and Raman measurements. (2) The Se atoms doped into MoS₂ improve the electrical conductivity as Se is more metallic than S. This hypothesis was further confirmed by electrochemical impedance spectroscopy (EIS) measurements in 0.5 M H₂SO₄ (Fig. 4c). The Se-doped MoS₂ only showed a charge transfer resistance (R_{ct}) 650 Ω , much smaller than that of MoS₂ (1945 Ω), demonstrating that Se doping dramatically enhances the electron transfer.

The effects of Se dopant concentration on the HER performance of Se-doped MoS₂ were then probed by LSV measurements. Fig S4 shows that the HER performance of the Se-doped MoS₂ increased with the Se content. Other than the HER activity, stability is another important characteristic used to evaluate an electrocatalyst. To investigate the stability of the Se-doped MoS₂, we determined the HER activity of the Se-doped MoS₂ at a constant potential of -0.25 V for 9000s. After a long period of 9 000s, only a slight decrease in the current density was observed for the Se-doped MoS₂, suggesting superior stability (Fig. 4d).

In conclusion, we have developed an effective high-temperature annealing method for the synthesis of Se-doped MoS₂ nanosheets. The Se-doped MoS₂ exhibits promising HER activity with a low overpotential of approximately 140 mV, a large cathodic current density, and a small Tafel slope of 55 mV/dec, much better than the undoped MoS₂ catalyst. We attribute the improved performance to the enhanced electrical conductivity that facilitates rapid electron transfer from the

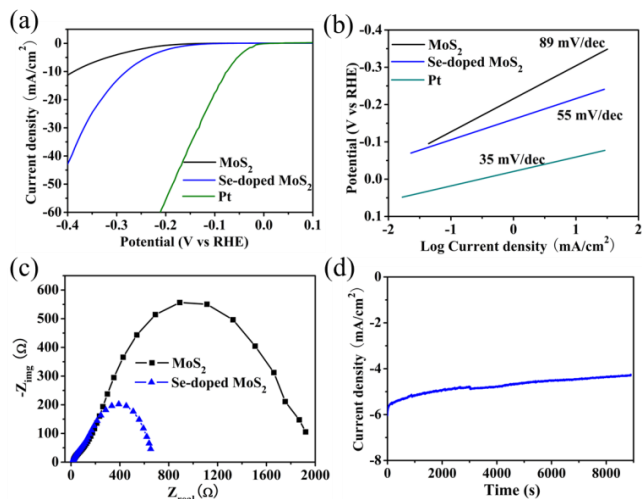


Fig. 4 HER performance of MoS₂ and Se-doped MoS₂ nanosheet catalysts. (a) Polarization curves, (b) Tafel plots of MoS₂, Se-doped MoS₂ and Pt electrode at scan rate 10 mV/s in 0.5 M H₂SO₄. (c) EIS Nyquist plots of MoS₂ and Se-doped MoS₂. (d) The durability test of Se-doped MoS₂ with applied voltage of -250 mV vs. RHE over 9, 000s in 0.5 M H₂SO₄.

electrode to the catalyst and the improved active edge sites.

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